

Organic synthesis

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T. W. Greene, P. G. M. Wuts *Protective Groups in Organic Synthesis*

P. J. Kocienski *Protecting Groups*

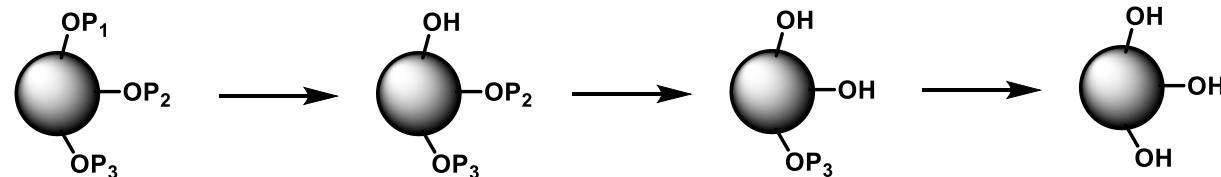
- the substrate contains reactive functional groups (typically OH, NH, CO, COOH ...) that are not compatible with reaction conditions

two additional steps in the synthetic sequence (installation & removal)

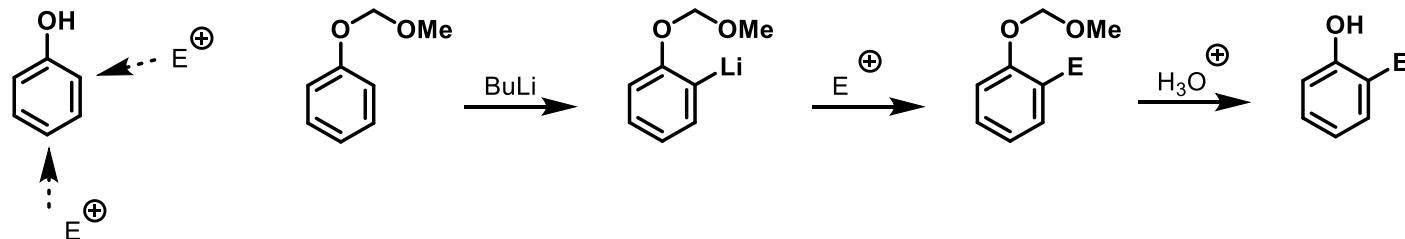


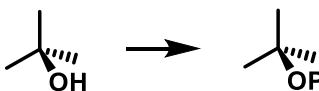
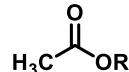
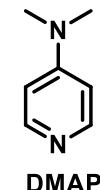
Young, I. S.; Baran, P. S. *Nature Chemistry* **2009**, 1, 193.
„Protecting-group-free-synthesis as an opportunity for invention“

orthogonally protected substrates: several different Ps that can be selectively introduced and removed

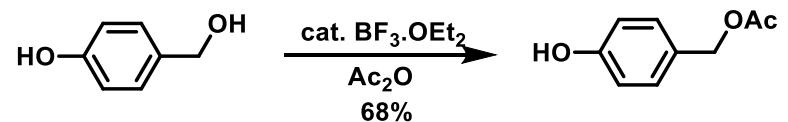


- some Ps can be used to direct (regio)selectivity of particular transformations

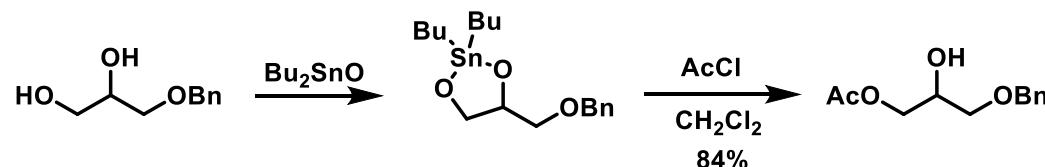


**esters:****acetates****Ac-OR**formation: typically: acetylating agent (Ac_2O , AcCl) + base (pyridine, TEA, DMAP)

also:

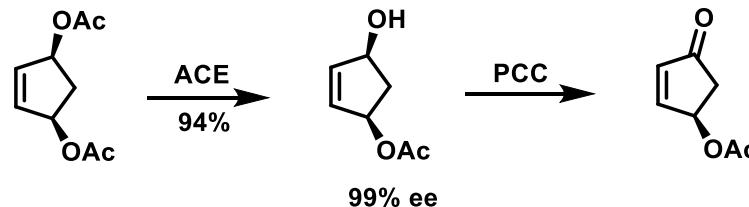
*Chem. Pharm. Bull.* **1981**, 29, 3202.

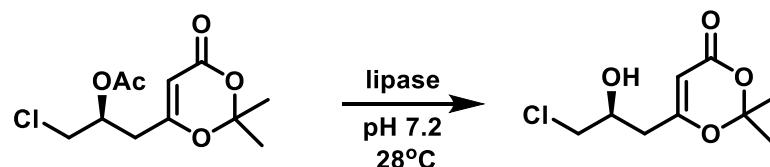
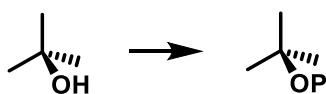
• acetylation of more nucleophilic OH

*Synthesis* **1989**, 225.*Tetrahedron* **1985**, 41, 643.cleavage: basic hydrolysis (K_2CO_3 in MeOH; NH_3 in MeOH)

several OH groups in the molecule: acetate can migrate

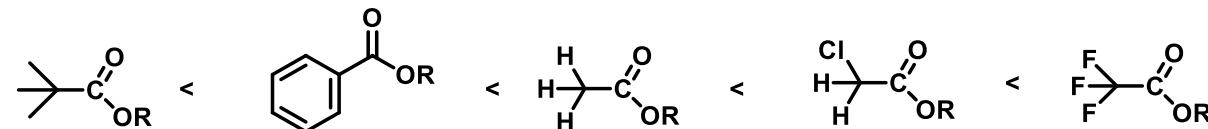
some lipases can cleave acetates enantioselectively (under mild conditions)

*Tetrahedron Lett.* **1986**, 27, 1255.



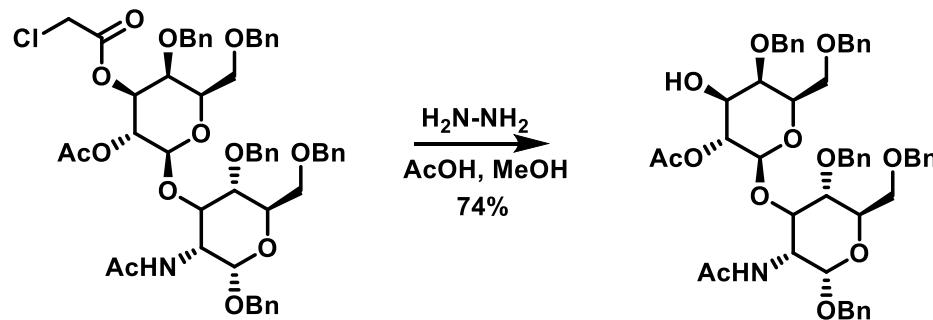
Tetrahedron: Asymmetry **1991**, *2*, 343.

ease of basic hydrolysis:

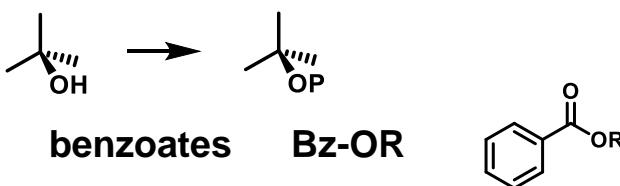


strong base (KOH/MeOH)

pH 7

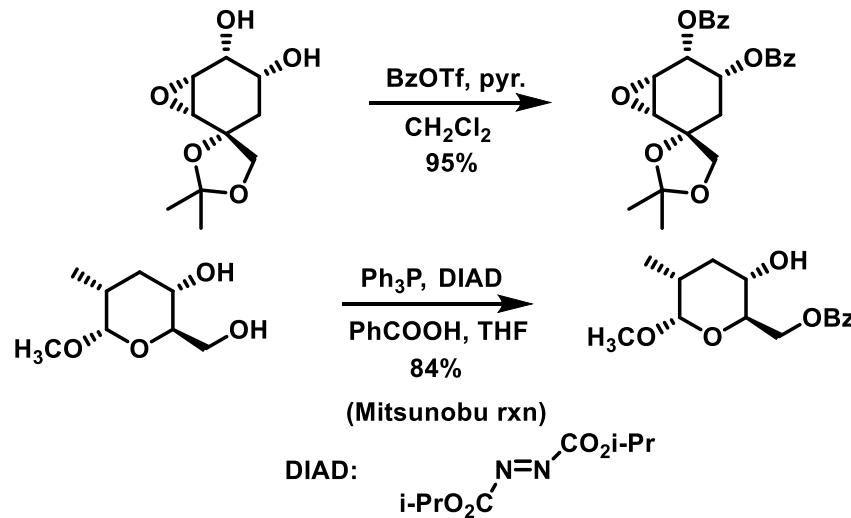


Tetrahedron **1992**, *48*, 4713.



formation: Bz_2O , $\text{BzCl} + \text{base}$ (pyridine, TEA)

- in polyhydroxylated systems typically much more selective than acetylation



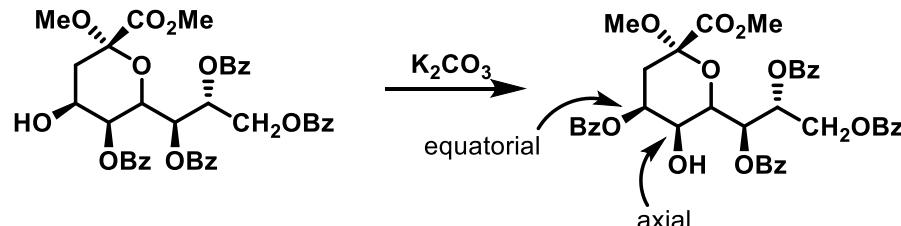
J. Org. Chem. **1984**, *49*, 3875.

Tetrahedron Lett. **1989**, *30*, 1037.

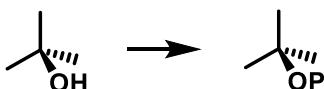
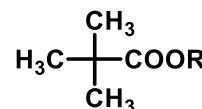
cleavage: basic hydrolysis (NaOH in MeOH ; TEA in MeOH)

migration: typically to much lesser extent than with acetates

(but can be forced, if thermodynamically more stable isomer is formed)

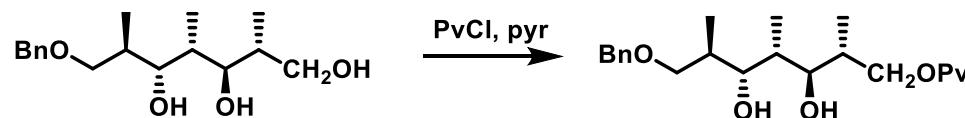


J. Am. Chem. Soc. **1988**, *110*, 3929.

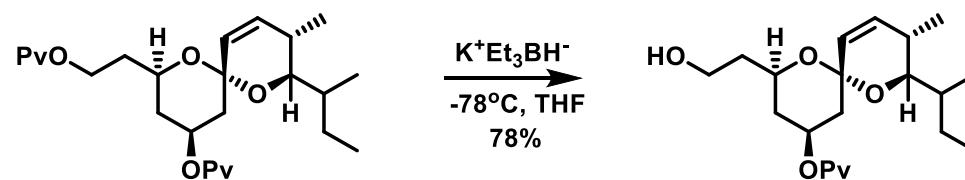
**pivaloates****Pv-OR**

formation: PvCl + base (pyridine, TEA)

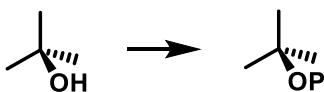
- primary OHs can be selectively acylated

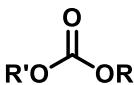


cleavage: strong base (KOH in MeOH, hydrides)



J. Am. Chem. Soc. **1989**, *111*, 2967.



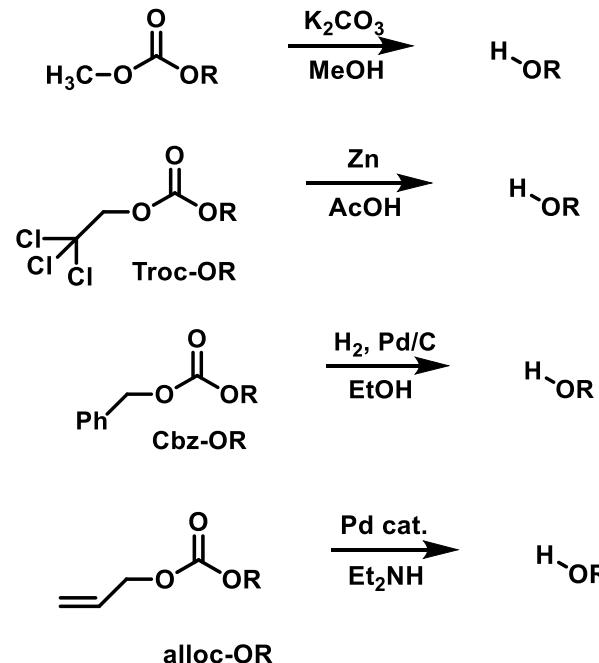
carbonates: 

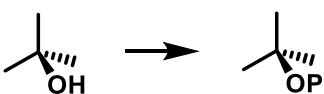
- more stable than esters towards basic hydrolysis

formation: $\text{R}'\text{OCOCl} + \text{base}$ (pyridine, TEA)

cleavage: in general, basic hydrolysis

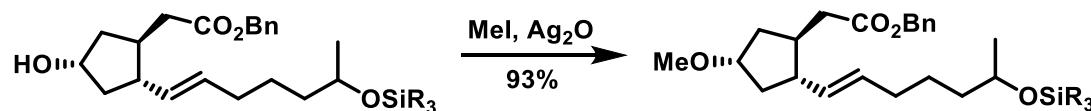
but: conditions can be specific for different carbonates



**ethers:**

methyl ether **Me-OR** $\text{H}_3\text{C}-\text{O}-\text{R}$

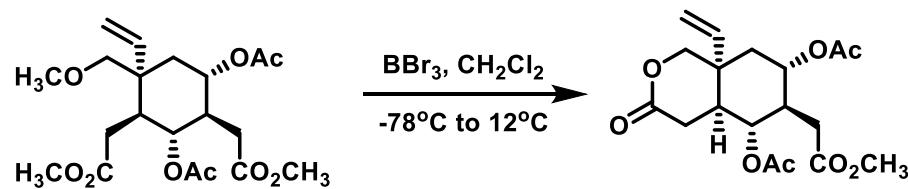
formation: MeI , Me_2SO_4 + base (NaOH , NaH , Ag_2O); CH_2N_2



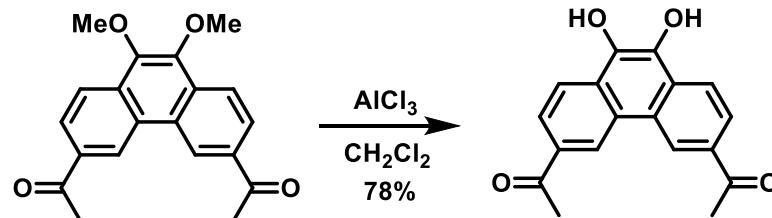
J. Am. Chem. Soc. **1980**, *102*, 7583.

cleavage:

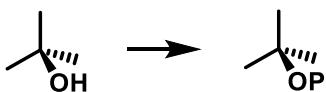
1. Lewis acids (BBr_3 , TMSI , AlCl_3)



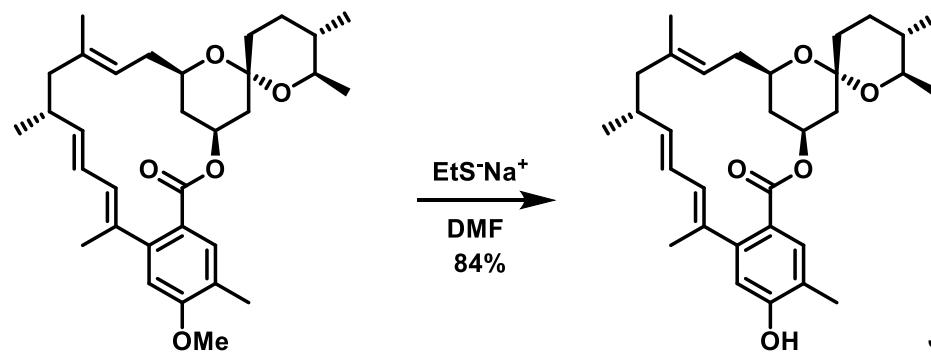
J. Am. Chem. Soc. **1977**, *99*, 5773.



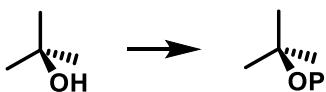
J. Org. Chem. **2000**, *65*, 7602.



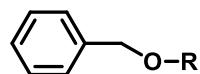
2. strong nucleophiles (phenolic methyl ethers)



J. Am. Chem. Soc. 1986, 108, 2662.

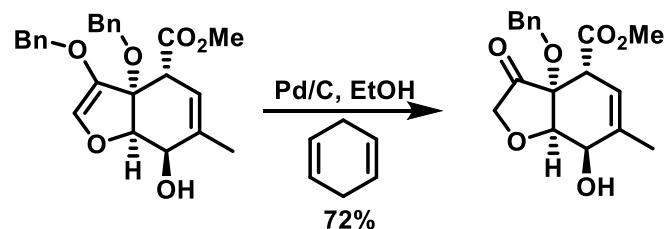


benzyl ether Bn-OR

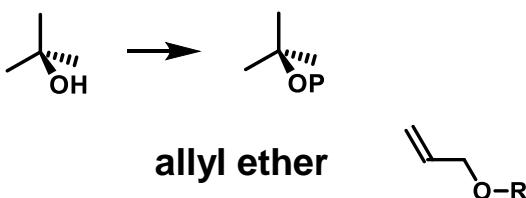


formation: BnBr + base (NaH)

cleavage: hydrogenolysis (H₂, Pd/C, EtOH)

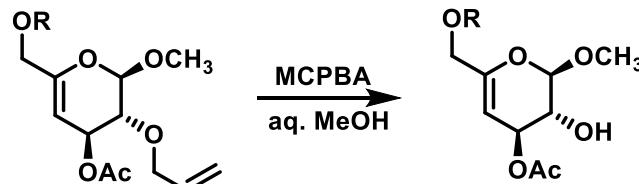


J. Am. Chem. Soc. 1984, 106, 8327.



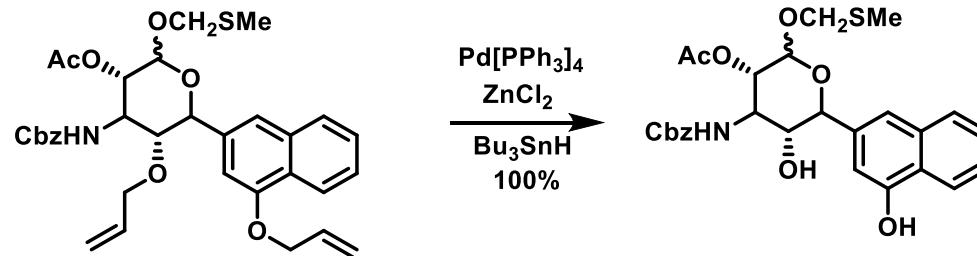
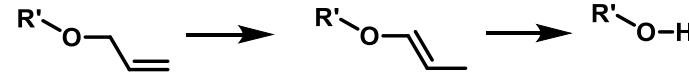
formation: CH₂=CH-CH₂Br + base (NaH)

cleavage: 1. oxidative (SeO₂, H₂O₂, MCPBA)

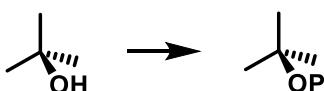


Tetrahedron **1990**, *46*, 5365.

2. Pd-catalyzed

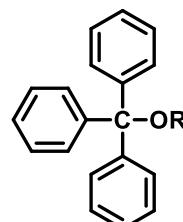


J. Org. Chem. **1992**, *57*, 644.

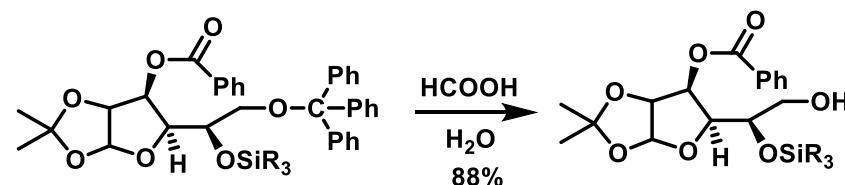
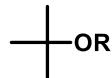


triphenylmethyl ether

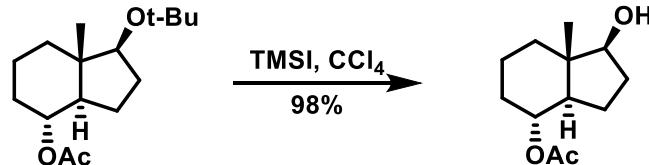
trityl-OR, Tr-OR

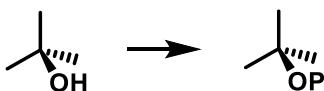
formation: $\text{Ph}_3\text{CCl} + \text{base}$ (DMAP, NaH)

cleavage: acidic conditions

*Tetrahedron Lett.* **1986**, 27, 579.*t*-butyl ether*t*-Bu-OR

- protection of phenols

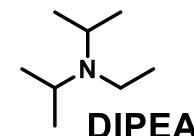
formation: $\text{t-BuBr} + \text{pyr. or H}^+ + \text{C=C}$ cleavage: H^+ , Lewis acids*J. Am. Chem. Soc.* **1982**, 104, 2945.



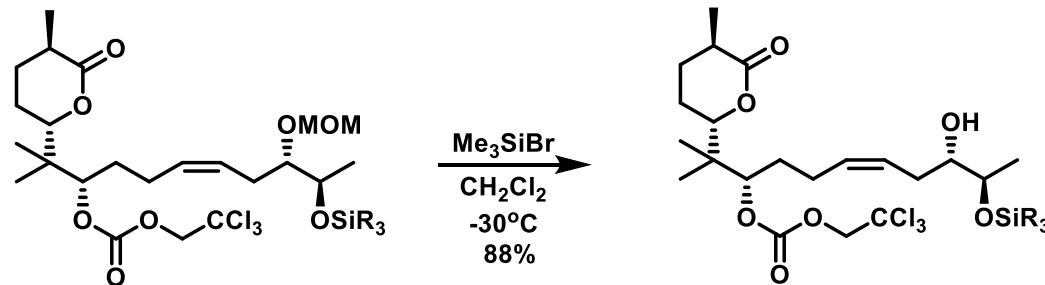
acetals

methoxymethyl ether **MOM-OR** $\text{H}_3\text{C}-\text{O}-\text{CH}_2-\text{O}-\text{R}$

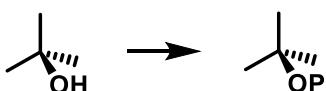
formation: $\text{MeOCH}_2\text{Cl} + \text{base}$ (DIPEA, NaH)



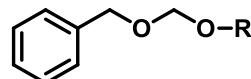
cleavage: acidic conditions (HCl/MeOH , TMSBr, $\text{BF}_3\cdot\text{OEt}_2$)



Tetrahedron Lett. **1984**, 25, 2515.

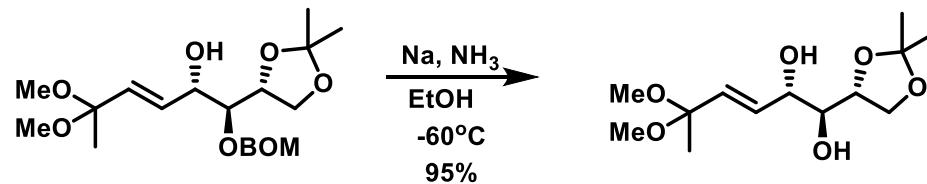


benzyloxymethyl ether BOM-OR

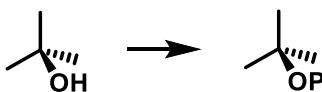


formation: $\text{BnOCH}_2\text{Cl} + \text{base (DIPEA)}$

cleavage: hydrogenolysis ($\text{H}_2/\text{Pd/C}$); Na/NH_3

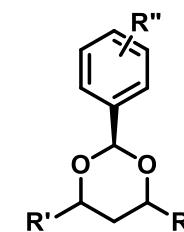
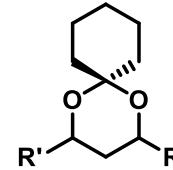
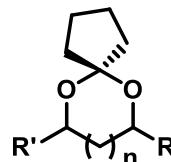
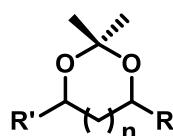


J. Am. Chem. Soc. **1987**, 109, 3981.



1,2- a 1,3 diols

acetals

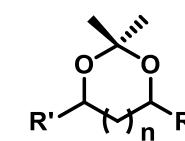
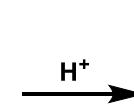
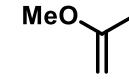
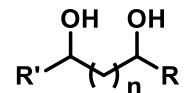


acetonides

cyclopentylidene ketals

cyclohexylidene ketals

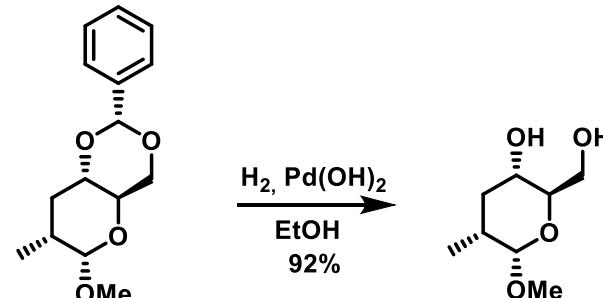
benzylidene acetals

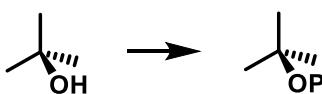
formation: H⁺

polyols:

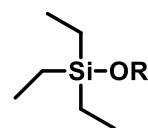
acetonides: typically 1,2-

benzylidene acetals: typically 1,3-

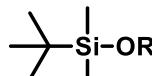
cleavage: H⁺, H₂OLewis acids + hydride donor (Et₃SiH)reduction (H₂, Pd/C) of benzylidene acetals*Tetrahedron Lett.* **1989**, 30, 1037.

**silyl ethers**

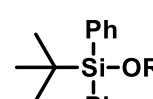
TMS-OR



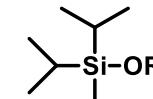
TES-OR



TBS-OR



TBDPS-OR



TIPS-OR

formation: R_3SiCl or $\text{R}_3\text{SiOTf} + \text{base}$ (imidazole; DIPEA; 2,6-dimethylpyridine)

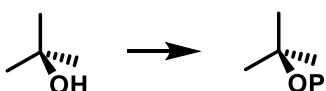
cleavage: H^+

$\text{K}_2\text{CO}_3/\text{MeOH}$ (TMSOR)

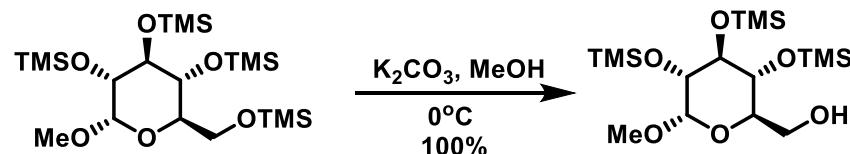
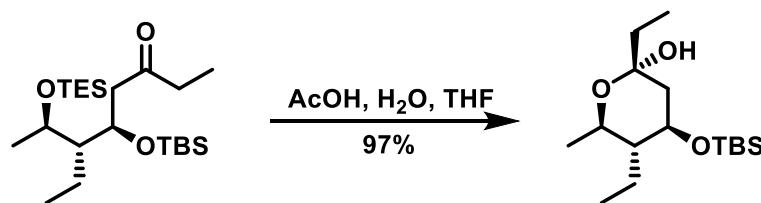
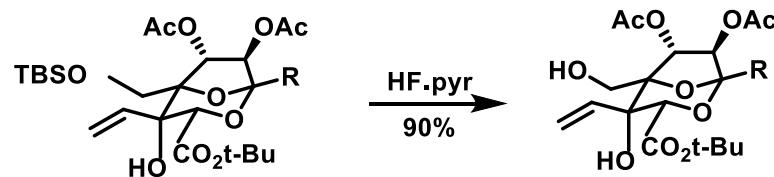
source of F⁻ (BuN⁺F⁻, HF.pyr, HF.Et₃N)

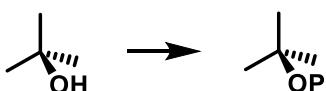
- ***selective cleavage under mild (neutral) conditions***

silyl ether	half life NaOH/MeOH	half life HCl/MeOH
$\text{C}_6\text{H}_{13}\text{OTMS}$	< 1 min	< 1 min
$\text{C}_6\text{H}_{13}\text{OTBS}$	> 24 h	< 1 min
$\text{C}_6\text{H}_{13}\text{OTIPS}$	> 24 h	55 min
$\text{C}_6\text{H}_{13}\text{OTBDPS}$	> 24 h	225 min

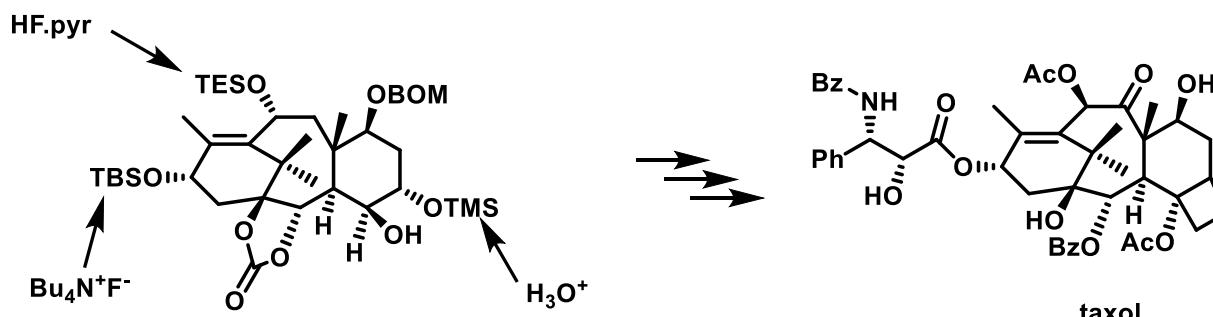
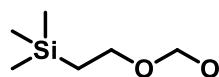
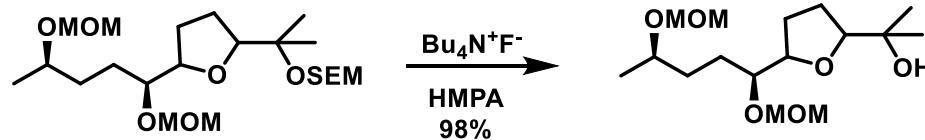


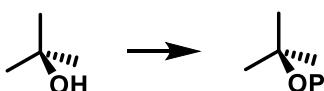
selective cleavage of silyl ethers

*Can. J. Chem.* **1965**, *43*, 2004.*Liebigs Ann. Chem.* **1986**, 1281.*J. Am. Chem. Soc.* **1976**, *32*, 2157.



sequential removal of silyl ethers

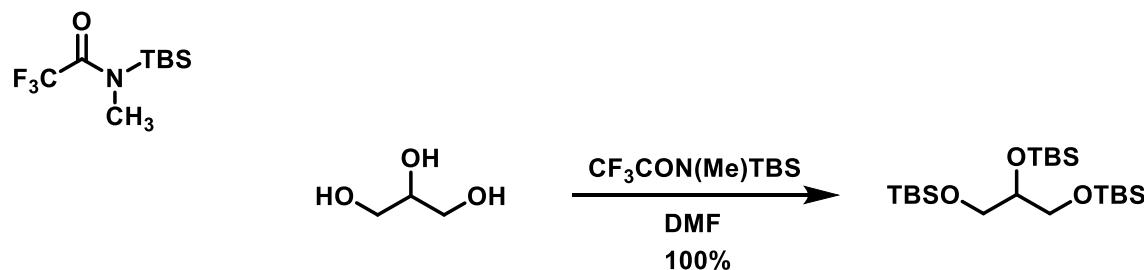
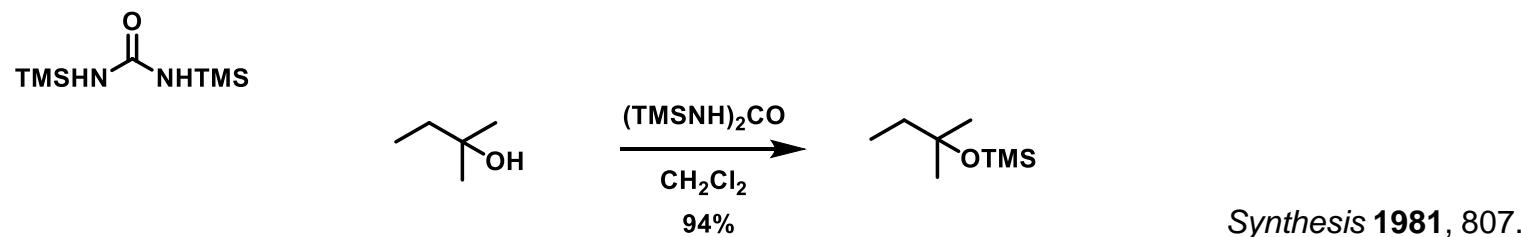
*J. Am. Chem. Soc.* **1994**, *116*, 1599.**2-(trimethylsilyl)ethoxymethyl ether SEM-OR**formation: $\text{TMSCH}_2\text{CH}_2\text{OCH}_2\text{Cl} + \text{base (DIPEA)}$ cleavage: 1. acidic conditions
2. fluoride*Tetrahedron Lett.* **1988**, *29*, 5417.



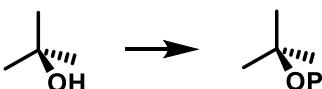
Si-F : 582 kJ/mol (Si-O : 452 kJ/mol C-H : 411 kJ/mol C-C : 346 kJ/mol)

Si-N : 355 kJ/mol

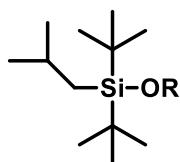
- silylated amines are significantly less stable than silylated alcohols
- N-silylated compounds can be used for transfer of the silyl group



J. Org. Chem. **1982**, 57, 3336.



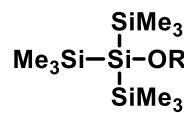
- **silyl esters:** significantly more labile compared to silyl ethers
- **modern and non-traditional Si-based protecting groups**



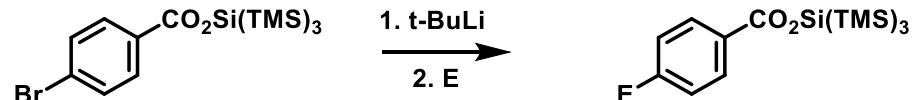
BIBSOR

- very resistant to bases/nucleophiles
- BIBS esters are quite stable

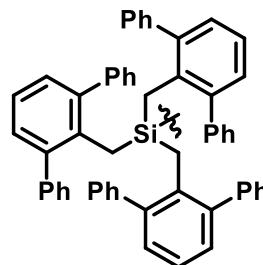
Org. Lett. **2011**, 13, 4120.

(TMS)₃SiOR

- „supersilyl“
- esters are quite stable



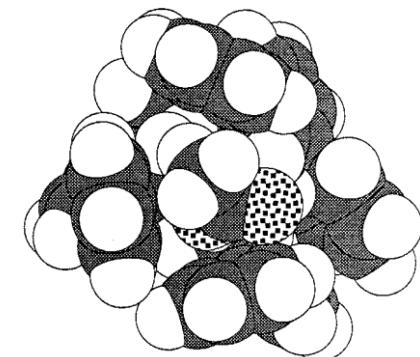
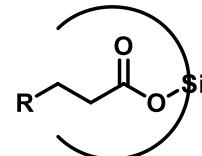
Angew. Chem. Int. Ed. **2013**, 52, 8165.



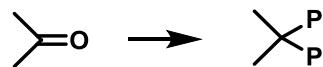
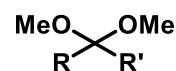
TDS

tris(2,6-diphenylbenzyl)silyl

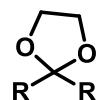
- esters resistant to LiAlH₄, RLi etc.



J. Am. Chem. Soc. **2000**, 122, 10238.

**acetals/ketals**

dimethyl acetal



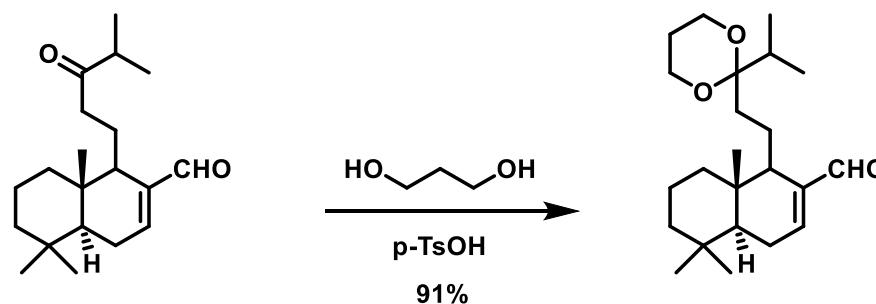
1,3-dioxolane



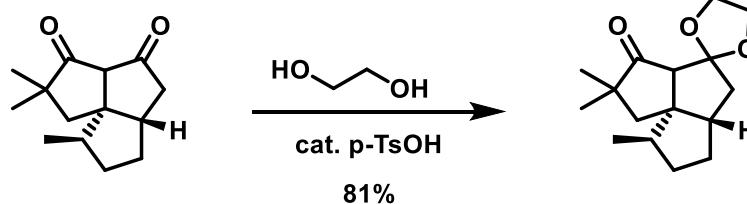
1,3-dioxane

formation: $\text{H}^+ + \text{alcohol}$
 $\text{HC(OMe)}_3 + (\text{Lewis}) \text{ acid}$

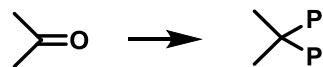
- aldehydes typically more reactive than ketones



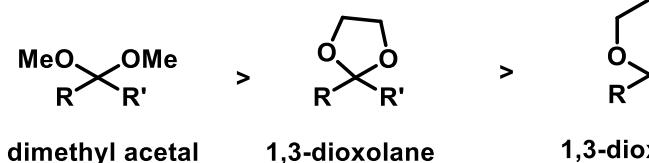
Tetrahedron Lett. 1982, 23, 1087.



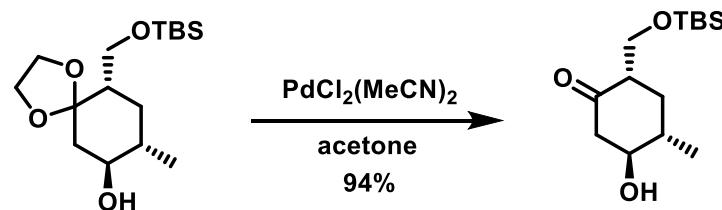
J. Am. Chem. Soc. 1986, 108, 800.



cleavage: H^+ , H_2O

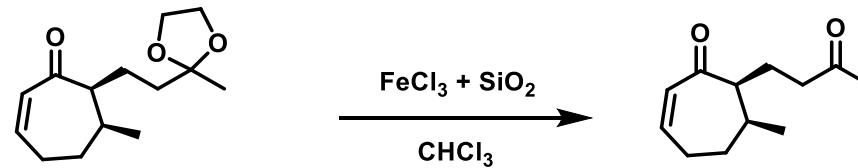


cat. $\text{PdCl}_2(\text{MeCN})_2$ + acetone

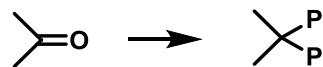


Tetrahedron Lett. **1987**, 28, 5755.

$\text{FeCl}_3 + \text{SiO}_2$

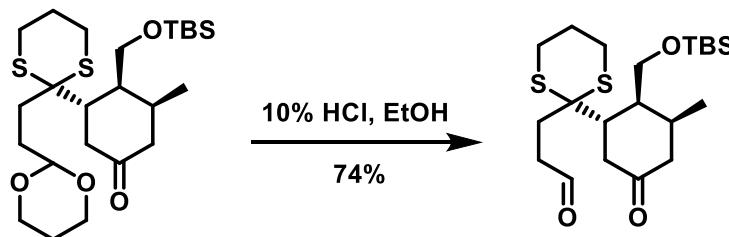


Tetrahedron Lett. **1987**, 28, 2489.

**cyclic dithioacetals/ketals**

formation: $\text{HS}(\text{CH}_2)_n\text{SH} + (\text{Lewis})\text{ acid}$

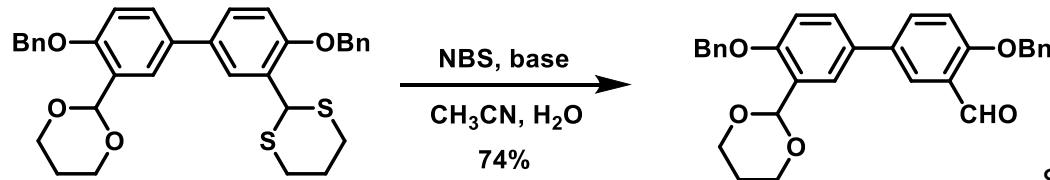
- dithioacetals are significantly less sensitive to acids than acetals



J. Org. Chem. **1985**, *50*, 1190.

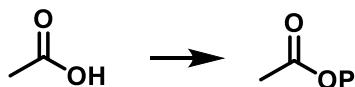
cleavage: conversion to a better leaving group (and then hydrolysis)

- coordination of S with metals: $\text{Hg}(\text{ClO}_4)_2$, CuCl_2 , CuO
- oxidation: MCPBA, Ac_2O , TEA
- alkylation: MeI

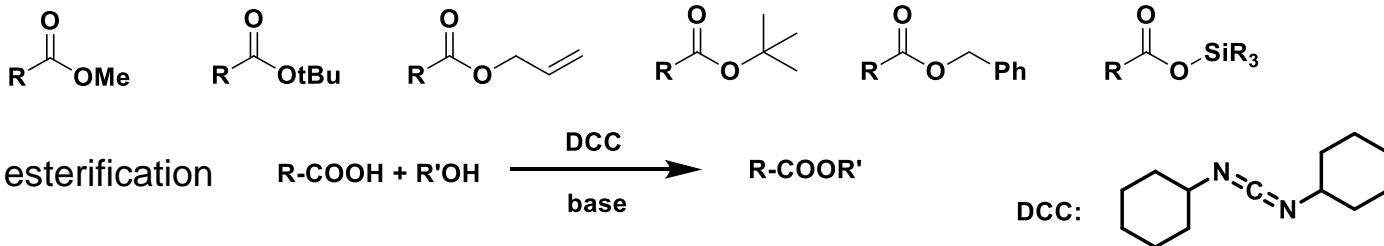


Synthesis **1992**, 1025.

Protecting Groups



esters



cleavage: methyl esters: basic hydrolysis (LiOH , MeOH), nucleophilic cleavage (LiI , NaCl)

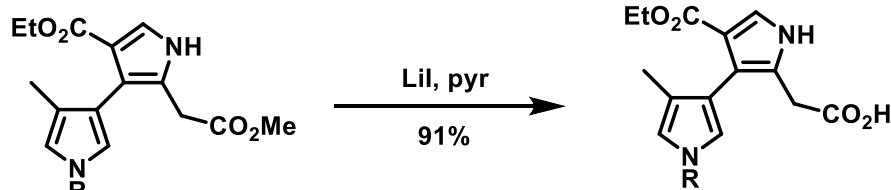
t-butyl esters: acidic hydrolysis (CF_3COOH)

allyl esters: Pd-catalyzed cleavage ($\text{Pd}(\text{PPh}_3)_4$)

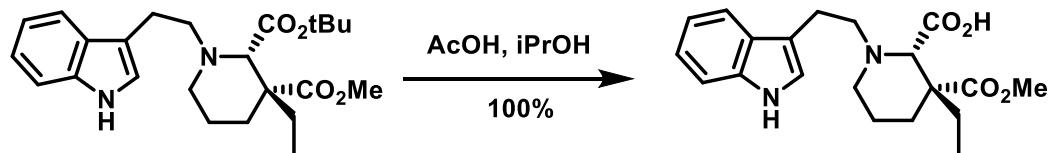
benzyl esters: hydrogenolysis (H_2 , Pd/C)

silyl esters: fluoride, acidic & basic hydrolysis

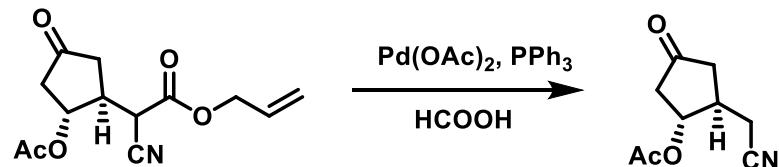
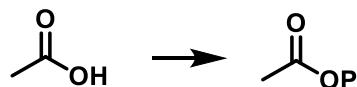
(less stable than silyl ethers)



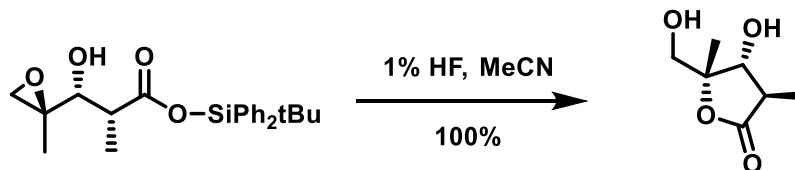
J. Chem. Soc., Chem. Commun. **1984**, 389.



J. Org. Chem. **1990**, 55, 3068.



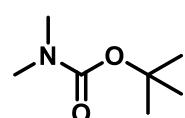
Tetrahedron Lett. 1991, 32, 2409.



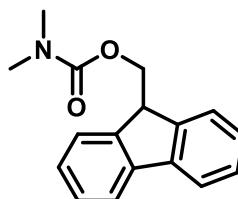
Tetrahedron Lett. 1982, 23, 4199.



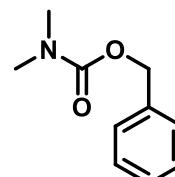
carbamates



Boc



Fmoc



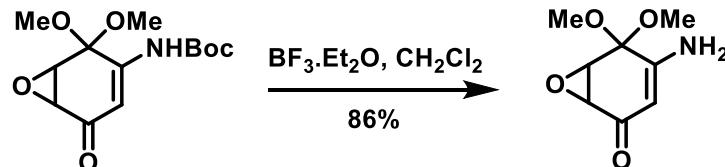
Cbz

formation: ROCOCl or $(\text{ROCO})_2\text{O}$ + base

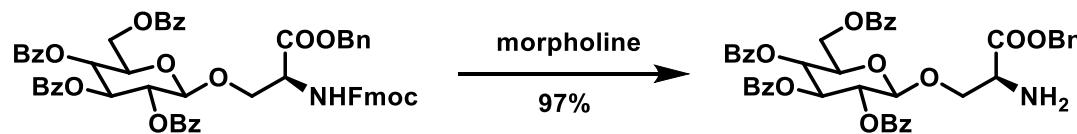
cleavage: Boc: CF_3COOH (+ PhOMe); Lewis acids

Fmoc: amine (piperidine, morpholine)

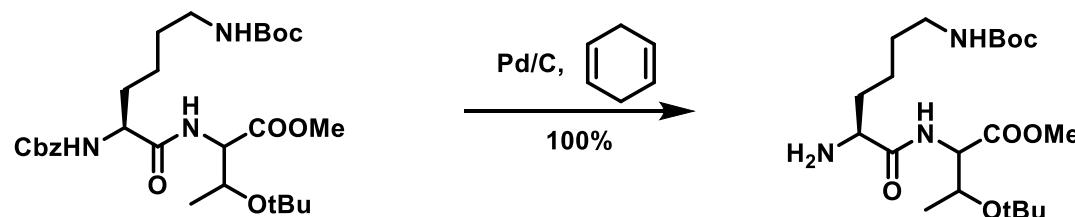
Cbz: H₂, Pd/C



Synth. Commun. 1997, 27, 1819.



Angew. Chem. Int. Ed. **1983**, *22*, 62.

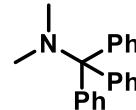


The Practice of Peptide Synthesis 1984, 158.

alkylated amines



Bn

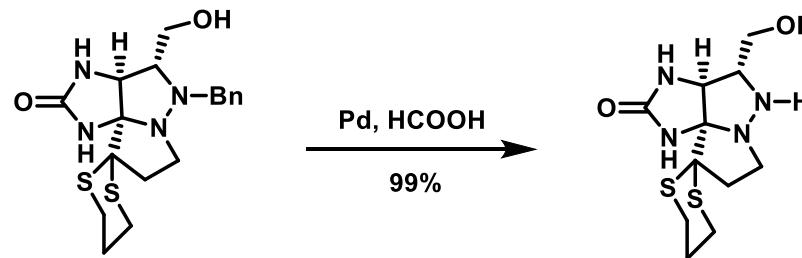


Tr

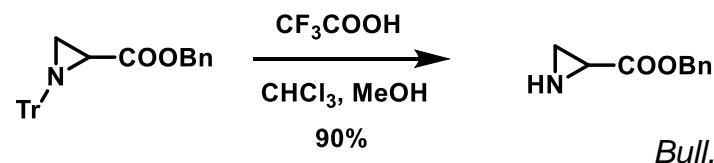
formation: BnBr or TrCl + base (NaH)

cleavage: Bn: hydrogenolysis

Tr: hydrogenolysis, CF_3COOH



J. Am. Chem. Soc. 1984, 106, 5594.

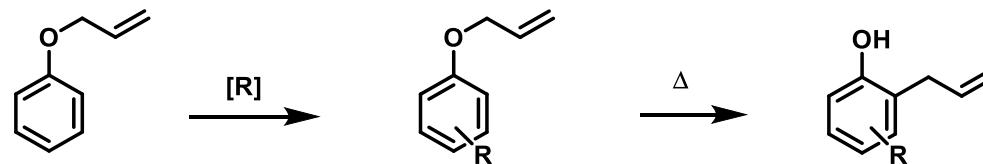


Bull. Chem. Soc. Jpn. 1978, 51, 1577.

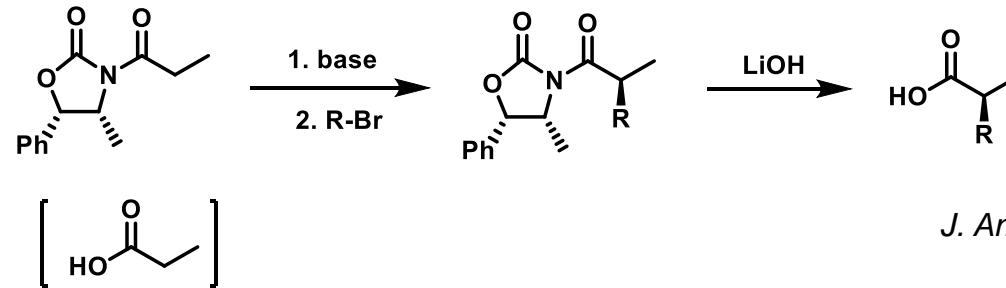
„combined“ use of protecting groups

protection of reactive centers *plus*:

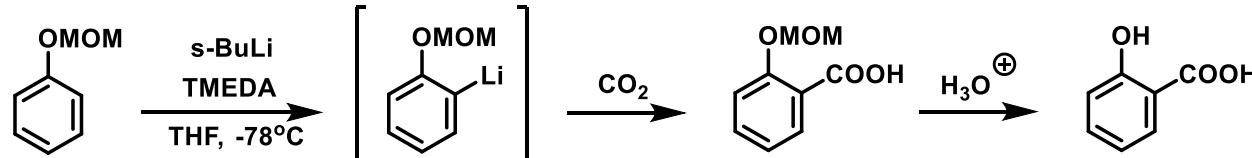
- incorporation of the P atoms into the target molecule (e.g. Claisen rearrangement of allyl ethers)



- diastereoselectivity (chiral Ps; „chiral auxiliary“ – e.g. Evans oxazolidinones)

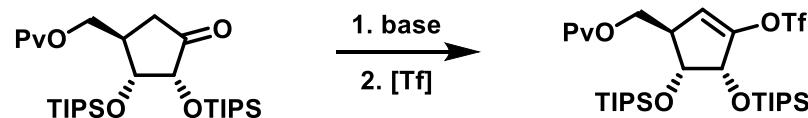


- regioselectivity (e.g. directed ortho-metallation using MOM, CONRR' etc.)



„combined“ use of protecting groups

- protections of more reactive centers (one primary, one adjacent)



J. Org. Chem. **2017**, *82*, 3382.

